	Application No.	A multipopular
	Application No.	Applicant(s)
Notice of Allowability	10/736,090	HOKE ET AL.
	Examiner	Art Unit
	Phu Vu	2871
The MAILING DATE of this communication appears on the cover sheet with the correspondence address All claims being allowable, PROSECUTION ON THE MERITS IS (OR REMAINS) CLOSED in this application. If not included herewith (or previously mailed), a Notice of Allowance (PTOL-85) or other appropriate communication will be mailed in due course. THIS NOTICE OF ALLOWABILITY IS NOT A GRANT OF PATENT RIGHTS. This application is subject to withdrawal from issue at the initiative of the Office or upon petition by the applicant. See 37 CFR 1.313 and MPEP 1308.		
1. This communication is responsive to 6/20/06.		
2. The allowed claim(s) is/are 10-20 and 45-52.		
3.		
Attachment(s) 1. Notice of References Cited (PTO-892) 2. Notice of Draftperson's Patent Drawing Review (PTO-948) 3. Information Disclosure Statements (PTO-1449 or PTO/SB/O Paper No./Mail Date	6. ☐ Interview Summary Paper No./Mail Dat 98), 7. ☑ Examiner's Amendr	te

An examiner's amendment to the record appears below. Should the changes and/or additions be unacceptable to applicant, an amendment may be filed as provided by 37 CFR 1.312. To ensure consideration of such an amendment, it MUST be submitted no later than the payment of the issue fee.

Authorization for this examiner's amendment was given in a telephone interview with Michael Fogarty on 8/29/06.

The application has been amended as follows: Claims 3-6 and 21-44 have been canceled as they are directed to nonelected inventions.

Response to Arguments

Applicant's arguments, see appeal brief, filed 6/20/06, with respect to the rejection of claims 10-18 and 45-52 have been fully considered and are persuasive. The rejection of claims 10-18 and 45-52 has been withdrawn.

Allowable Subject Matter

Claims 10-20 and 45-52 are allowed.

The following is an examiner's statement of reasons for allowance:

Regarding claims 10-20 and 45-52, there is no prior art of record that teaches solely or in combination a LC cell comprising a transparent top plate a substrate

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including an active area, the substrate and the top plate collectively defining a cavity; a reservoir in at least one of the substrate and the tope plate and connected to the cavity; liquid crystal material within the cavity and the reservoir; and an electrode located in the reservoir to attract ionic contaminants.

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Fujioka as previous cited discloses a similar system that uses electrodes to attract ionic contaminants to an exterior region of the LC area however omits formation of a reservoir and placement of electrodes within the reservoir. Hatano as previously cited discloses Field Emission display with electrodes in a reservoir to attract ionic contaminants however this is not analogous art as the device operate in a fundamentally different from LCD displays. Fujioka's display operates similarly to a cathode ray tube where the beam trajectory, is negatively affected by ions found in the gases of the display. In the current invention the presence of ionic contaminants causes a breakdown of LC itself, therefore, the combination is unfeasible due to fundament differences between the technologies.

Any comments considered necessary by applicant must be submitted no later than the payment of the issue fee and, to avoid processing delays, should preferably accompany the issue fee. Such submissions should be clearly labeled "Comments on Statement of Reasons for Allowance."

Conclusion

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Any inquiry concerning this communication or earlier communications from the examiner should be directed to Phu Vu whose telephone number is (571)-272-1562. The examiner can normally be reached on 8AM-5PM M-F.

If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, David Nelms can be reached on (571)-272-1787. The fax phone number for the organization where this application or proceeding is assigned is 571-273-8300.

Information regarding the status of an application may be obtained from the Patent Application Information Retrieval (PAIR) system. Status information for published applications may be obtained from either Private PAIR or Public PAIR. Status information for unpublished applications is available through Private PAIR only. For more information about the PAIR system, see http://pair-direct.uspto.gov. Should you have questions on access to the Private PAIR system, contact the Electronic Business Center (EBC) at 866-217-9197 (toll-free). If you would like assistance from a USPTO Customer Service Representative or access to the automated information system, call 800-786-9199 (IN USA OR CANADA) or 571-272-1000.

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> Andrew Schechter PRIMARY EXAMINER

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